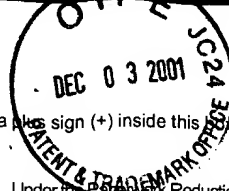


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INFORMATION DISCLOSURE STATEMENT BY APPLICANT (use as many sheets as necessary)			Application Number	09/938,399
			Filing Date	August 23, 2001
			First Named Inventor	Barnes, Michael
			Group Art Unit	
			Examiner Name	
Sheet 1 of			Attorney Docket Number	016301-039900US

U.S. PATENT DOCUMENTS						
Examiner Initials *	Cite No. ¹	U.S. Patent Document		Name of Patentee or Applicant of Cited Document	Date of Publication of Cited Document MM-DD-YYYY	Pages, Columns, Lines, Where Relevant Passages or Relevant Figures Appear
		Number	Kind Code ² (if known)			
mu	AA	5,413,671		Ketchum	05-09-1995	
mu	AB	5,451,259		Krogh	09-19-1995	
mu	AC	5,540,384		Erickson et al.	07-30-1996	
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mu	AF	5,855,957		Yuan	01-05-1999	
mu	AG	6,066,575		Reardon et al.	05-23-2000	
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	AV							
	AW							
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	AY							

Examiner Signature	<i>K Moore</i>	Date Considered	10/21/02
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EXAMINER: Initial if reference considered, whether or not citation is in conformance with MPEP 609. Draw line through citation if not in conformance and not considered. Include copy of this form with next communication to applicant.

¹ Unique citation designation number. ² See attached Kinds of U.S. Patent Documents. ³ Enter Office that issued the document, by the two-letter code (WIPO Standard ST.3). ⁴ For Japanese patent documents, the indication of the year of the reign of the Emperor must precede the serial number of the patent document. ⁵ Kind of document by the appropriate symbols as indicated on the document under WIPO Standard ST. 16 if possible. ⁶ Applicant is to place a check mark here if English language Translation is attached.

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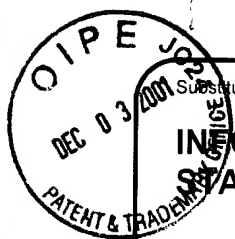
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Application Number	09/938,399
Filing Date	August 23, 2001
First Named Inventor	Barnes, Michael
Group Art Unit	
Examiner Name	
Attorney Docket Number	016301-039900US

OTHER PRIOR ART -- NON PATENT LITERATURE DOCUMENTS

Examiner Initials *	Cite No. ¹	Include name of the author (in CAPITAL LETTERS), title of the article (when appropriate), title of the item (book, magazine, journal, serial, symposium, catalog, etc.), date, page(s), volume-issue number(s), publisher, city and/or country where published.	T ²
<i>fu</i>	AZ	PETER VAN ZANT, "Atmospheric Pressure CVD Systems", Microchip Fabrication, A Practical Guide to Semiconductor Processing", (1997), 359-363, Third Edition	
	BA	ROY G. GORDON, et al., "Silicon Dimethylamido Complexes and Ammonia as Precursors for the Atmospheric Pressure Chemical Vapor Deposition of Silicon Nitride Thin Films", Chem. Mater., (1990), pp. 480-482, Vol. 2, No. 5	
	BB	M. L. HAMMOND, "Epitaxial Silicon Reactor Technology - A Review; Part I: Reactor Technology", Solid State Technology, (May 1988), pp. 159-164	
	BC	V. Y. DOO, et al., "Preparation and Properties of Pyrolytic Silicon Nitride", Journal of the Electrochemical Society, (December 1966), pp. 1279-1281, Vol. 113, No. 12	
	BD	GEERT JANSEN, "Atmospheric Pressure Chemical Vapor Deposition of SiN using SiH ₄ and NH ₃ as precursors", (September 6, 1999), 32 pgs.	
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